

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Attn: OIPE

Takeshi KOBAYASHI

Group Art Unit: 1722

Application No.:

10/567,488

Docket No.: 126923

Filed: March 6, 2006

For:

METHOD FOR PRODUCING A WAFER

REQUEST FOR CORRECTION OF PALM RECORDS

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,

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WPB:LMS/hjr

Date: May 11, 2006

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PATENT AND TRADEMARK OFFICE

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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/567,488	03/06/2006	1722	1030	126923	7	20	1

25944 OLIFF & BERRIDGE, PLC P.O. BOX 19928 ALEXANDRIA, VA 22320



CONFIRMATION NO. 1001

FILING RECEIPT

OC000000018447666

Date Mailed: 04/11/2006

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Applicant(s)

Takeshi Kobayashi, Fukushima, JAPAN;

Assignment For Published Patent Application

SHIN-ETSU HANDOTAI CO., LTD., TOKYO, JAPAN

Power of Attorney: The patent practitioners associated with Customer Number 25944.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP04/11145 08/04/2004

Foreign Applications

JAPAN 2003-292558 08/12/2003 JAPAN 2003-292539 08/12/2003 JAPAN 2003-292596 12/08/2003

08/12/2005
If Required, Foreign Filing License Granted: 04/03/2006

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is US10/567.488

Projected Publication Date: 07/13/2006

Non-Publication Request: No

Early Publication Request: No

Title

Method for producing a wafer

Preliminary Class

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